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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/787,188	02/27/2004	Yoshiki Takata	1248-0934PUS1	4585
2292 7590 06/27/2008 BIRCH STEWART KOLASCH & BIRCH PO BOX 747 FALLS CHURCH, VA 22040-0747				
EXAMINER CHOI, JACOB Y				
ART UNIT 2885		PAPER NUMBER		
NOTIFICATION DATE 06/27/2008		DELIVERY MODE ELECTRONIC		

**Please find below and/or attached an Office communication concerning this application or proceeding.**

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

mailroom@bskb.com

### Office Action Summary

**Application No.**

10/787,188

**Applicant(s)**

TAKATA, YOSHIKI

**Examiner**

JACOB Y. CHOI

**Art Unit**

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --  
**Period for Reply**

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

**Status**

- 1) ☒ Responsive to communication(s) filed on 09 April 2008.  
2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.  
3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

**Disposition of Claims**

- 4) ☒ Claim(s) 1-14, 16-18 and 20-41 is/are pending in the application.  
4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.  
5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.  
6) ☒ Claim(s) 1-14, 16-18 and 20-41 is/are rejected.  
7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.  
8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

**Application Papers**

- 9) ☐ The specification is objected to by the Examiner.  
10) ☒ The drawing(s) filed on 20 March 2006 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  
11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

**Priority under 35 U.S.C. § 119**

- 12) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  
a) ☒ All b) ☐ Some \* c) ☐ None of:  
1. ☒ Certified copies of the priority documents have been received.  
2. ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.  
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

**Attachment(s)**

- 1) ☐ Notice of References Cited (PTO-892)  
2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)  
3) ☐ Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)  
Paper No(s)/Mail Date \_\_\_\_\_  
4) ☐ Interview Summary (PTO-413)  
Paper No(s)/Mail Date \_\_\_\_\_  
5) ☐ Notice of Informal Patent Application (PTO-152)  
6) ☐ Other: \_\_\_\_\_

## **DETAILED ACTION**

### ***Continued Examination Under 37 CFR 1.114***

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on April 9, 2008 has been entered.

### ***Response to Amendment***

Examiner acknowledges that the applicant has amended claims 1-5, 7-12, 14, 20, and 23-38. Currently, claims 1-14, 16-18, and 20-41 are pending in the application.

### ***Specification***

The specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

### ***Claim Rejections - 35 USC § 102***

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

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A person shall be entitled to a patent unless –

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

**Note:** claims in a pending application should be given their broadest reasonable interpretation. *In re Pearson*, 181 USPQ 641 (CCPA 1974).

Things clearly shown in reference patent drawing qualify as prior art features, even though unexplained by the specification. *In re Mraz*, 173 USPQ 25 (CCPA 1972).

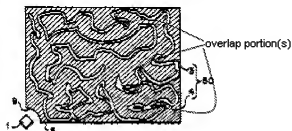
In order to be given patentable weight, a functional recitation must be supported by recitation in the claim of sufficient structure to warrant the presence of the functional language. *In re Fuller*, 1929 C.D. 172; 388 O.G. 279.

Claims **26-37** are rejected under 35 U.S.C. 102(e) as being anticipated by Yamashita et al. (USPN 7,004,610).

Regarding claims **26 and 32**, Yamashita et al. discloses an element body (e.g., 6 & 8) having a generally plate shape constituted with a material having a larger electric permittivity than air outside the element body (e.g., column 10, lines 40-50) and, in the inside of the element body (e.g., 6 & 8), a plurality of completely closed spaces (e.g., 3, 4, 50; Figures 4, 19, & 20) are disposed whose electric permittivity is smaller than that of the material constituting the element body (e.g., 6 & 8) and whose surfaces opposite to a radiation surface (e.g., Figures 1, 6, and 7) are generally flat, the element body (e.g., 6 & 8) comprising a first member (e.g., 6) having a radiation source (e.g., 1) disposed on a side thereof and a second member (e.g., 5) disposed on the radiation surface side (e.g., Figures 1, 6, and 7) in close adhesion (e.g., Figures 14-15) with the first member (e.g., 6), the completely closed spaces (e.g., 3, 4, and 50) being formed in both the first member (e.g., 6) and in the second member (e.g., 5).

Regarding claims 27 and 33, Yamashita et al. discloses at least some of the closed spaces in the first member (e.g., 6) are aligned with at least some of the closed spaces in the second member (e.g., Figure 1).

Regarding claims 28 and 34, Yamashita et al. discloses at least some of the closed spaces (e.g., 3, 4) in the second member partially overlap at least some of the closed spaces in the first member (e.g., Figure 20).



Regarding claims 29 and 35, Yamashita et al. discloses at least some of the closed spaces in the second member are offset from all closed spaces in the first member (e.g., Figure 20).

Regarding claims 30 and 36, Yamashita et al. discloses a plurality of the closed spaces include surfaces opposite to the radiation surface that are generally parallel to the radiation surface (e.g., Figures 2-4, and 18).

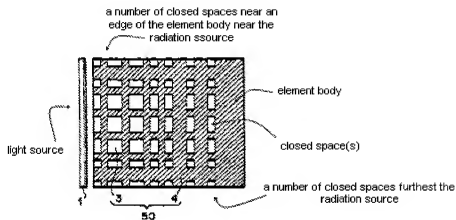
Regarding claims 31 and 37, Yamashita et al. discloses a plurality of the closed spaces include surface opposite to the radiation surface that are generally parallel to each other (e.g., Figures 2-4, and 18).

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims **1-14, 16-18, 20-25, and 38-41** are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamashita et al. (USPN 7,004,610).

Regarding claims **1** and **8**, Yamashita et al. discloses an element body (e.g., 6 & 8) has a generally plate shape (e.g., Figure 3) constituted with a material having a larger electric permittivity than air outside the element body (e.g., column 10, lines 40-50; "... *a composite layer 50 constituted of a low refractive index region (first refractive index region) 3 of a refractive index  $n_1$  and a high refractive index region of a refractive index  $n_2$  (second refractive index region) 4*") and, in the inside of the element body (e.g., 6 & 8), a plurality of completely closed spaces (e.g., 3, 4, 50; Figures 4, 19, & 20) of substantially uniform size are disposed whose electric permittivity is smaller than that of the material constituting the element body and whose surfaces opposite to a radiation surface are *generally* flat (e.g., Figure 1, 5, 6, 7), wherein a number of the completely closed spaces (e.g., 3, 4, 50; Figures 4, 19, & 20) near an edge of the element body near the radiation source is of greater density than the density of the completely closed spaces in a furthest portion of the element body (e.g., Figure 3).



Yamashita et al. fails to specifically show the two elongated light sources positioned opposite one another, where the number of closed spaces near an edge of the element body is greater than in center portion of the element body.

However, it would have been obvious to one having ordinary skill in the art at the time the invention was made to implement teachings of Yamashita et al. (e.g., Figure 3, columns 10-12, lines 60-45; "... low refractive index region 3 and the high refractive index region 4 are not limited to one having a substantially rectangular cross-section shape ... substantially semicircular structure, a structure where a cross-sectional shape of the high refractive index region 4 has a curved line partially or entirely ... or the like ... an array pattern of the low refractive index region 3 and the high refractive index region 4 in the composite layer 50, various types such as one any one of the aforementioned patterns combined with the other thereof can be used ... means for changing the occupation density of the high refractive index region 4, there are available a method simultaneously using plural pattern similar to those shown in FIGS. 2 to 4 and FIGS. 18 to 20 or other complex pattern changes, a method of setting similar pattern shapes and changing an area of the high refractive index region 4 from place to place, a

*method using completely identical pattern shapes and changing an array pitch (P) thereof, etc.”)* to variously locate different sizes and shapes of low and high refractive regions throughout the element body to further enhance the luminance of the over all LCD device, especially for using dual elongated light sources (e.g., Figure 5). The modification of rearranging the low and high refractive regions would be obvious, since it has been held that rearranging parts of an invention involves only routine skill in the art. *In re Japikse*, 86 USPQ 70. In addition, it would have been obvious to rearrange the closed spaces and its density, since the examiner takes Official Notice of that the closed spaces are commonly varied on the light guide member to effectively provide a uniform light output. Thus, placing greater density of closed spaces in a central portion of the element body would be within the level of ordinary skill in the art.

Regarding claims 2 & 9, Yamashita et al. further discloses the claimed invention, explained above. In addition, Yamashita et al. discloses a plurality of *closed spaces* are disposed whose surfaces opposite to the radiation surface are *generally* parallel to the radiation surface (e.g., Figures 2-4).

Regarding claims 3 & 10, Yamashita et al. further discloses the claimed invention, explained above. In addition, Yamashita et al. discloses a plurality of *closed spaces* is adjacently disposed whose surfaces opposite to the radiation surface are generally parallel to each other (e.g., Figures 2-3).

Regarding claims 4 & 11, Yamashita et al. further discloses the claimed invention, explained above. In addition, Yamashita et al. discloses a first member



having a radiation source (e.g., 1) disposed on a side thereof and a second member disposed on the radiation surface side are constituted to be in close adhesion (e.g., columns 4-8, lines 25-25), and the closed spaces are formed between the first member and the second member by the adhesion of faces of the first and second member (e.g., Figures 14-15).

Regarding claims 5 & 12, Yamashita et al. further discloses the claimed invention, explained above. In addition, Yamashita et al. discloses at least one member of the first member (e.g., 6) and the second member (e.g., 50 and/or 5) has recesses formed therein, and the recesses (e.g., 3, 4,) are disposed to constitute the closed spaces by joining the first member (e.g., 6) and the second member (e.g., 50 and/or 5).

Regarding claims 6 & 13, Yamashita et al. further discloses the claimed invention, explained above. In addition, Yamashita et al. discloses a total reflection-restraining layer such as a scatter layer is disposed in the radiation surface (e.g., 8, 10).

Regarding claims 7 & 14, Yamashita et al. further discloses the claimed invention, explained above. In addition, Yamashita et al. discloses the closed spaces are filled with solid layers (e.g., 3, 4) having a smaller electric permittivity than the material constituting the element body (e.g., 6 & 8).

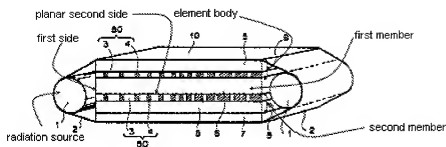
Regarding claims 23 & 24, Yamashita et al. further discloses the claimed invention, explained above. In addition, Yamashita et al. discloses a first member (e.g., 6) having a radiation source (e.g., 1) disposed on a side thereof and a second member (e.g., 50 and/or 5) disposed on a radiation surface of the first member rare constituted to be in closed adhesion (e.g., columns 4-8, lines 25-25), the second member including

a planer surface having a plurality of openings therein (e.g., 3), wherein face contact between the second member planar surface and the first member closes the spaces in the second member (e.g., Figures 1-20).

Regarding claims **25**, Yamashita et al. discloses an element body (e.g., 6 & 8) having a *generally* plate shape constituted with a material having a larger electric permittivity than air outside the element body (e.g., column 10, lines 40-50; "... a composite layer 50 constituted of a low refractive index region (first refractive index region) 3 of a refractive index  $n1$  and a high refractive index region of a refractive index  $n2$  (second refractive index region) 4") and, in the inside of the element body, a plurality of completely closed spaces are disposed (e.g., 3, 4, 50; Figures 4, 19, & 20), the electric permittivity of the completely closed spaces being smaller than the electrical permittivity of the material constituting the element body (e.g., 6 & 8), and a number of closed spaces (e.g., 3, 4, 50; at the top) near an edge of the element body near the radiation source is greater than in a furthest portion of the element body (e.g., Figure 3), wherein the element body (e.g., 6 & 8; Figure 5) comprises a first member (e.g., 6) having a first side facing a radiation source (e.g., 1) and a planar second side and a second member having (e.g., 8, 3, 4, 50; at the bottom) a planar side having a plurality of openings (e.g., 3, 4, 50) having *generally* flat bottoms (e.g., Figure 5), the second member (e.g., 50 and/or 5) being mounted on the first member (e.g., 6) with portions of the second member (e.g., 8, 3, 4, 50; at the bottom) planar side in face contact with the

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first member (e.g., 6) planar second side thereby closing (e.g., 4) the plurality of openings (e.g., Figure 5).



Yamashita et al. fails to specifically show the two elongated light sources positioned opposite one another, where the number of closed spaces near an edge of the element body is greater than in center portion of the element body.

However, it would have been obvious to one having ordinary skill in the art at the time the invention was made to implement teachings of Yamashita et al. (e.g., Figure 3, columns 10-12, lines 60-45; "... low refractive index region 3 and the high refractive index region 4 are not limited to one having a substantially rectangular cross-section shape ... substantially semicircular structure, a structure where a cross-sectional shape of the high refractive index region 4 has a curved line partially or entirely ... or the like ... an array pattern of the low refractive index region 3 and the high refractive index region 4 in the composite layer 50, various types such as one any one of the aforementioned patterns combined with the other thereof can be used ... means for changing the occupation density of the high refractive index region 4, there are available a method simultaneously using plural pattern similar to those shown in FIGS. 2 to 4 and FIGS. 18 to 20 or other complex pattern changes, a method of setting similar pattern

*shapes and changing an area of the high refractive index region 4 from place to place, a method using completely identical pattern shapes and changing an array pitch (P) thereof, etc.”)* to variously locate different sizes and shapes of low and high refractive regions throughout the element body to further enhance the luminance of the over all LCD device, especially for using dual elongated light sources (e.g., Figure 5). The modification of rearranging the low and high refractive regions would be obvious, since it has been held that rearranging parts of an invention involves only routine skill in the art. *In re Japikse*, 86 USPQ 70. In addition, it would have been obvious to rearrange the closed spaces and its density, since the examiner takes Official Notice of that the closed spaces are commonly varied on the light guide member to effectively provide a uniform light output. Thus, placing greater density of closed spaces in a central portion of the element body would be within the level of ordinary skill in the art.

Regarding claims **16-18**, **20-22**, and **38-41**, Yamashita et al. discloses the structural limitations of the applicant's claimed invention, explained in above paragraphs.

Yamashita et al. failed to disclose method of use of a particular structure.

It would have been obvious to one of ordinary skill in the art at the time of the invention to recite the use of structural limitations of Yamashita et al. Also, it has been held that to be entitled to weight in method claims, the recited structure limitations therein must affect the method in a manipulative sense, and not to amount to the mere claiming of a use of a particular structure. *Ex parte Pfeiffer*, 1962 C.D. 408 (1961).

***Response to Arguments***

Applicant's arguments with respect to claims 1-14, 16-18, and 20-41 have been considered, but rejections are made differently. Also, Applicant's arguments filed April 9, 2008 have been fully considered but they are not persuasive.

***Conclusion***

Any inquiry concerning this communication or earlier communications from the examiner should be directed to JACOB Y. CHOI whose telephone number is (571)272-2367. The examiner can normally be reached on Monday-Friday (10:00-7:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Jong-Suk (James) Lee can be reached on (571) 272-7044. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Art Unit: 2885

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